Form 1449 (Modified)

Information Disclosure
Statement By Applicant

(Use Several Sheets if Necessary)

Atty Docket No. Application No.:
NOVL085/NVLS-2875
Applicant:
Wang et al.
Filing Date
February 23, 2004
Group
February 23, 2004
2812

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Examiner		Docu	ment	Publication	Country or		Sub-	Trans	lation
Initial	No.	Nq.		Date	Patent Office	Class	class	Yes	No

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Form 1449 (Modified)	Atty Docket No.	Application No.:
	NOVL085/NVLS-2875	10/785,235
Information Disclosure	Applicant:	
Statement By Applicant	Wang et al.	
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(Use Several Sheets if Necessary)	February 23, 2004	2812

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Examiner	1	Document	Publication	Country or		Sub-	Trans	lation
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